

X-ray Photoelectron Spectroscopy and Ab Initio Molecular-Dynamics Studies of an Air-Exposed C₆₀ Film

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X-ray photoelectron spectra of C₆₀ films exposed to air of *ca.* 20 % and 60 % humidity at 23 °C for 1 h are presented. It was found that the O 1s core peak appeared at a binding energy of 533.5 eV for the film exposed to air of *ca.* 60 % humidity, while no peak corresponding to the O 1s photoelectrons was observed for the film exposed to air of *ca.* 20 % humidity. The binding energy of 533.5 eV for the O 1s core peak is close to that of about 533 eV for the O 1s core peak of solid H₂O, while it is different from that of 537 eV for the O 1s core peak of solid O₂ on C₆₀ film. These facts indicate that the O 1s peak observed for the air-exposed C₆₀ film was due to H₂O molecules adsorbed on the film. The adsorption state of H₂O molecules on the C₆₀ molecule is discussed on the basis of the results obtained using first-principle molecular dynamics calculations within a local density approximation.

Key words: XPS, C₆₀ film, O 1s core peak, first-principle molecular-dynamics calculations

1. INTRODUCTION

Since the discovery of an effective production method for C₆₀ [1], there have been many reports on the electronic properties of pristine and metal-doped C₆₀ films applied to functional devices. In this field, the interaction between C₆₀ and molecular gases, in particular air (O₂, N₂, and H₂O), is one of the most important subjects from the viewpoint of C₆₀-based materials. For example, the effect of air on the resistivity [2,3] and photoconductivity [4-6] of C₆₀ films has been reported by several groups and it was found that O₂ molecules markedly affected these properties, while the effect of N₂ molecules was negligible. This indicates that the interaction between C₆₀ and N₂ does not have to be considered in the air-exposed C₆₀ films. On the other hand, water vapor can be adsorbed on the film as well as O₂ molecules and this should be considered. However, little attention has been paid to the interaction between C₆₀ and H₂O until now, although there have been many experimental [7-18] and theoretical [19-22] reports on the interaction between solid C₆₀ and various gases such as O₂, N₂, CO, Ar, and He. The aim of the present work is to study the interactions between C₆₀ and O₂/H₂O molecules for the C₆₀ films exposed to air of moderate humidity at a given temperature using X-ray photoelectron spectroscopy (XPS) [23] in combination with first-principle molecular-dynamics calculations [24].

2. EXPERIMENT

The details of the C₆₀ film preparation has been described elsewhere [25]. Thin films of C₆₀ were deposited on a Au-(more than 1 nm thick) coated stainless steel substrate. The thickness of the C₆₀ film was estimated to be about 100 nm.

After deposition of the C₆₀ film on the substrate, this sample was taken out of the vacuum chamber and exposed to air of moderate humidity (*ca.* 20 % and 60 %) at 23 °C for 1 h prior to introducing it into an

XPS apparatus (VG: Escalab Mk-II). Humidity in the experimental room was controlled using both an air conditioner and a supersonic water vapor generator, and it was monitored using a thermohygrograph (Sato Keiryoki Co., Ltd.). Room temperature was also maintained at 23 °C using the air conditioner.

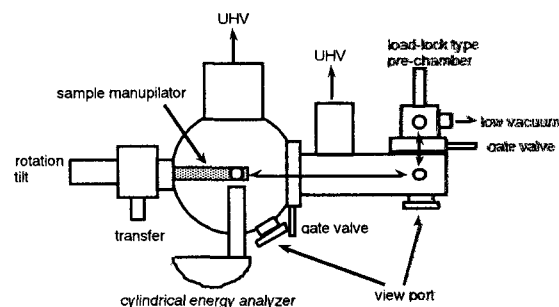


Figure 1. Schematic representation of an apparatus for the study of air-exposed C₆₀ film by x-ray photoelectron spectroscopy.

Figure 1 shows a schematic representation of an XPS system for the study of the air-exposed C₆₀ film. Three vacuum chambers are separated by two gate valves. The main chamber is equipped with an ultrahigh vacuum pumping system, an X-ray source (MgK α : 1253.6 eV), an energy analyzer (the energy resolution for the full width at half maximum of the Ag 3d_{5/2} is 0.6 eV), and a five-axis sample manipulator (X, Y, Z, rotation, tilt). The base pressure of this vacuum chamber was 5x10⁻¹⁰ Torr. By rotating the sample holder, the incident angle of photoelectrons emitted from the sample into the analyzer was adjusted to 90°. The second chamber is also a UHV system similar to that of the main chamber and is equipped with a system for sample transfer from this chamber to the main chamber. The third chamber is a load-lock prechamber equipped with a low vacuum system (10⁻³ Torr) for introducing the sample into the second

chamber.

Various XPS data handling such as smoothing, background removal and peak fitting were carried out by a Fisons analysis software package (ECLIPS). The Au $4f_{7/2}$ (83.7 eV) transition was used as a reference peak for estimation of the binding energy of other peaks.

We measured the XPS spectra between the center and edge of the sample area. When we compared the binding energy of the C 1s core peak observed for the center area with that for the edge area, both C 1s core peaks had the same binding energy (284.7 eV). This shows that there was no effect of charge-up on the sample upon X-ray irradiation. The substrate temperature was maintained at room temperature during XPS measurement.

3. COMPUTATIONAL METHOD

We used a self-consistent mixed-basis full-potential method for the calculation of C_{60} -gas interactions. A combined set of plane waves and Bloch sums of localized functions is employed as basis functions, thus leading to a very efficient representation of the system containing both highly localized and delocalized electrons. The present method is based on the density-functional theory with local density-functional approximation.

For the basis set of C_{60} , 60 1s and 60 $2p_x$, 60 $2p_y$, 60 $2p_z$ atomic orbitals and 2109 plane waves are adopted. The exponential damping factors α and β for the 1s and 2p atomic wave functions were chosen to be $1/0.106$ and $1/0.133 \text{ \AA}^{-1}$, respectively. The real space was divided into $64 \times 64 \times 64$ meshes where 3.185 meshes correspond approximately to 1 a.u. = 0.529 \AA . The details of this method has been described elsewhere [24].

4. RESULTS AND DISCUSSION

Figure 2 shows the XPS spectrum in the binding energy range of 0-1000 eV for the C_{60} film exposed to air of ca. 20% humidity at 23 °C for 1 h. It is interesting to note that no peak corresponding to the O 1s photoelectrons (530-540 eV) was observed below a detection limit of less than 0.1-At% in the present XPS system. The reproducibility of this result was confirmed by obtaining the XPS spectrum under similar conditions.

We estimated the escape depth of the C 1s photoelectrons using a modified Bethe equation [26] and found it to be about 54 \AA . Since the C_{60} film has a fcc structure with a lattice constant of 14.17 \AA [27] at room temperature and the mean ball diameter of a C_{60} molecule is 7.10 \AA [28], the present XPS spectra provided information on almost four unit cells below the film surface. Furthermore, the escape depth of the O 1s photoelectrons is on the same order as that of C 1s photoelectrons [29]. This suggests that oxygen atoms were not present not only on the surface of the

air-exposed C_{60} film but also within four unit cells below the surface.

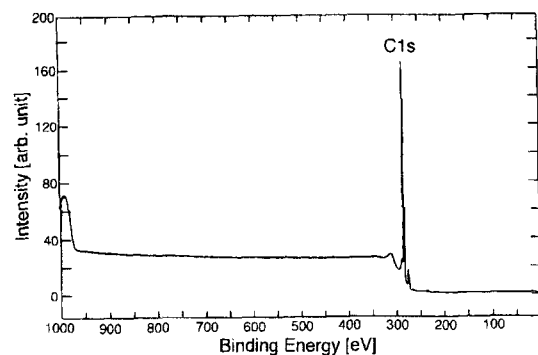


Figure 2. X-ray photoelectron spectrum in the binding energy range of 0-1000 eV for the C_{60} film exposed to air of ca. 20% humidity at 23 °C for 1 h.

When a C_{60} film was exposed to air of ca. 60% humidity at 23 °C for 1 h, the O 1s peak was first detected. These facts suggest that the O 1s core peak was attributed not to O_2 molecules but to H_2O molecules adsorbed on the C_{60} film. Figure 3 shows the photoelectron spectrum of the O 1s for the film exposed to air of high humidity in the binding energy range of 520-550 eV. It was found that the O 1s core peak appeared at a binding energy of 533.5 eV. Kroll et al. [8] have reported XPS spectra of solid O_2 adsorbed on a C_{60} film at 20 K and found that the binding energy of the O 1s core peak for the solid O_2 was about 537 eV (543-544 eV for free O_2 in Ref30), which is different from our result. On the other hand, the binding energy of the O 1s core peak for solid H_2O has been reported to be about 533 eV (539.7 eV for free H_2O in Ref30), which is in good agreement with our result.

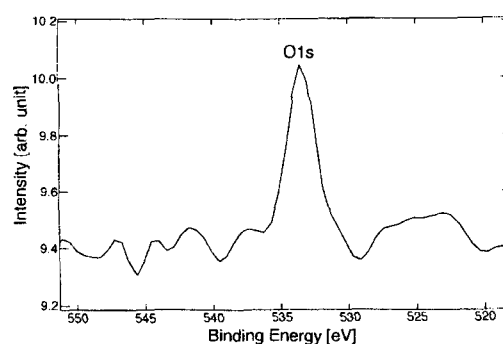


Figure 3. The photoelectron spectrum of the O 1s in the binding energy range of 520-550 eV for the C_{60} film exposed to air of ca. 60% humidity at 23 °C for 1 h.

From the XPS intensities of the O 1s and C 1s peaks, the amount of oxygen was estimated to be 1.8-At%, while the amount of carbon to be 98.2-At%. This corresponds numerically to that one H_2O molecule is adsorbed on one C_{60} molecule within 54 \AA depth of the C_{60} film. However, this conclusion is hard to be accepted by the following reasons. The

activation energy for O₂ diffusion into the C₆₀ bulk lattice has been estimated to be 180 meV [5]. The molecular size of a H₂O molecule (about 3 Å) is greater than that of an O₂ molecule (2.4 Å) and the distance between adjacent C₆₀ molecules is 3 Å in the fcc bulk structure, so that the activation energy for H₂O diffusion into the bulk lattice is expected to be larger than that for O₂ molecules. Since the thermal translational energy of a molecule is about 38 meV at 23 °C, it is speculated that H₂O molecules diffuse only slightly into the bulk lattice under the present conditions. From these reasons, a few solid H₂O layers are assumed to be formed on the C₆₀ film exposed to air of high humidity at 23 °C. Consequently, the present O1s core peak originates from the H₂O layers adsorbed on the air-exposed C₆₀ film. In addition, because the present experiments have been carried out without photoirradiation, the O1s core peak observed in Fig. 3 does not arise from photochemical products such as CO (535.7 eV), CO₂ (534.5 eV), and other carbonyl (532.8 eV) compounds formed on the C₆₀ film [9]. Indeed, Wohlers et al. [31] have recently reported on the reaction of C₆₀ and C₇₀ with molecular oxygen using X-ray absorption and photoelectron spectroscopy. When C₆₀ films (50-100 nm thick) were exposed to 500 mbar of oxygen for 5 min at 300 K (27 °C), no oxygen content could be observed by near edge X-ray absorption spectroscopy, as shown in Fig.1 in Ref.31. This demonstrated that molecular oxygen is unlikely to be adsorbed on the C₆₀ films at 300 K. This is consistent with our present results.

The XPS results suggest that H₂O is physisorbed on C₆₀. We next discuss the interaction between H₂O and C₆₀. Previously, Williams et al. [21] estimated the intermolecular energy between C₆₀ and various gas molecules such as O₂ and H₂O by semi-empirical calculations based on atom-atom potentials. They found that the C₆₀-O₂ binding energy was -1.13 to -1.35 kcal/mol (-49.0 to -58.5 meV). Since the translational energy of a molecule at 300 K is about 40 meV, their result predicts that O₂ molecules are easily desorbed from C₆₀ films at room temperature and can explain our present results. On the other hand, the C₆₀-H₂O binding energy was -1.06 to -1.25 kcal/mol (-46 to -54.2 meV) in their report. This predicts that H₂O is more easily desorbed from C₆₀ films than O₂ at room temperature, which is in conflict with our results. Williams *et al.* calculated these interactions using an atom-atom potential expressed as the form, $A \exp(-Br) - Cr^{-6}$, where *A*, *B*, and *C* denote constants and *r* represents an interatomic distance. The first and second terms represent the repulsive exchange and the attractive dispersion interactions, respectively. However, besides these terms, it is important to consider the electrostatic and induction terms for the accurate estimation of the intermolecular interactions [32,33]. Indeed, H₂O molecules are electronically polarized and have a permanent dipole moment in the molecule. This implies that the bonding energy due to the electrostatic and induction interactions for the C₆₀-H₂O system becomes more significant than that for

the C₆₀-O₂ system. Thus H₂O molecules are expected to be more strongly bound to the C₆₀ film than O₂ molecules.

In order to understand the interaction between C₆₀ and H₂O molecules more satisfactorily, we examine the bonding energy between C₆₀ and H₂O molecules using the *ab initio* molecular-dynamics calculations based on density-functional theory [24]. Prior to discussing the adsorption state of H₂O on C₆₀, we compare the chemical shift in the O1s binding energy between experimental and theoretical results in order to confirm the reliability of the present calculations. The O1s energy shift of H₂O before and after adsorption was theoretically estimated to be 4.43 eV, while that was experimentally obtained to be 6.23 eV. This discrepancy is due to the fact that present calculations do not consider the interaction between adjacent H₂O molecules.

Figure 4 shows the equilibrium configuration for the adsorption state of H₂O molecule on the C₆₀. We found that H₂O molecule is adsorbed above the hexagon of C₆₀ by about 3.0 Å. The bonding energy between these molecules is estimated to be 0.38 eV, which is comparable to that for hydrogen bonding. This indicates that H₂O molecules are more strongly physisorbed on the C₆₀ molecule than O₂ molecules. As shown in Fig. 4, it is interesting to note that the hydrogen atoms of H₂O face to the hexagon of C₆₀.

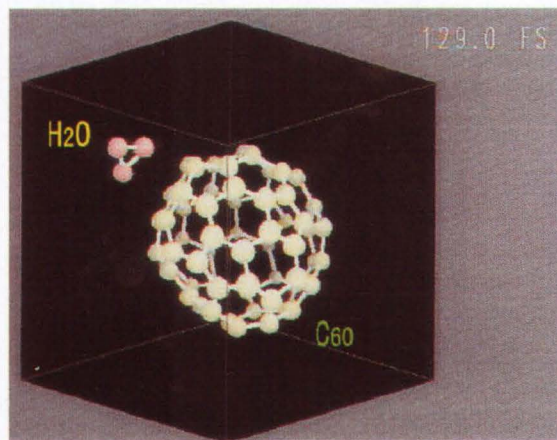


Figure 4. The equilibrium structure of H₂O adsorbed on C₆₀ obtained using *ab initio* molecular-dynamics calculations. The two hydrogen atoms of H₂O face the hexagon of C₆₀.

5. SUMMARY

X-ray photoelectron spectra of the C₆₀ films exposed to air of moderate humidity of about 20 % and 60 % at 23 °C for 1 h were presented. It was found that the O1s core peak appeared at a binding energy of 533.5 eV for the film exposed to air of ca. 60 % humidity, while no peak corresponding to the O1s photoelectrons was observed for the film exposed to air of ca. 20% humidity. The binding energy of 533.5 eV for the O1s core peak was close to that of about 533

eV for the O1s photoelectrons of solid H₂O, while it was different from that of 537 eV for the O1s photoelectrons of solid O₂ on C₆₀ film. Consequently, the O1s core peak was assigned to H₂O layers adsorbed on the C₆₀ film. Ab initio molecular-dynamics calculations of the C₆₀-H₂O system found that H₂O molecule is physisorbed above the hexagon of C₆₀ by about 3.0 Å forwarding its hydrogen atoms to this hexagon.

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